

No	ITEM	SPEC	RESULT
1	Total Focus Deviation	Max-Min $\leq 0.20\mu\text{m}$	0.196 $\mu\text{m}$
2	Lens Astigmatism	$ V-H  \leq 0.30\mu\text{m}$	0.109 $\mu\text{m}$
3	Lens Dynamic Distortion	X,Y = Within $\pm 50\text{nm}$	X = -2nm~40nm Y = 15nm~42nm
4	Wafer Flatness Accuracy	1) Flat Within $\geq$ Max-Min 3.0 $\mu\text{m}$ 2) L.F.S Within $\geq$ Max-Min 0.8 $\mu\text{m}$	1. 1.91 $\mu\text{m}$ 2. 0.58 $\mu\text{m}$
5	Exposure Power	Within $\geq 700\text{mW}/\text{cm}^2$	726 $\text{mW}/\text{cm}^2$
6	Illumination Uniformity	Within $\pm 1.5\%$	1.282%
7	Stage Precision Accuracy 1) Stepping Accuracy 2) Backlash Accuracy	1) $3\sigma \leq 50\text{nm}$ 2) $3\sigma \leq 50\text{nm}$	1) X: 10nm Y: 14nm 2) X: 13nm Y: 18nm
8	Wafer Pre-Alignment Repeatability	$3\sigma \leq 15\mu\text{m}$	X : 3.468 $\mu\text{m}$ Y : 6.846 $\mu\text{m}$ T : 2.371 $\mu\text{m}$
9	Integrator Accuracy	Target: Ave $\leq 1\%$	Ave Max = 0.025%
10	Alignment Accuracy 1) FIA-EGA 2) LSA-EGA	FIA-EGA = $ M  + 3\sigma \leq 75\text{nm}$ LSA-EGA = $ M  + 3\sigma \leq 75\text{nm}$	1) X = $\pm 18\text{nm}$ Y = $\pm 18\text{nm}$ 2) X = $\pm 15\text{nm}$ Y = $\pm 10\text{nm}$